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(54) Title: FILM COMPOSITION

(57) Abstract

A transparent multilayer film made from a polymer substrate, preferably polypropylene, is modified by a maleic anhydride modified propylene polymer, which can be located on a surface of the substrate and/or incorporated within the substrate, has a skin layer of ethylene vinyl alcohol copolymer which is coated with a transparent gas barrier layer, such as a metal oxide, specifically, silicon monoxide, silicon dioxide, aluminum oxide, magnesium oxide, boron oxide, calcium oxide and barium oxide and a mixture of two or more of the foregoing oxides.

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FILM COMPOSITION

The invention relates to a multi-layer film composition.

More specifically, the invention relates to a transparent
polymeric substrate having an ethylene vinyl alcohol copolymer

skin layer which is coated with a transparent barrier material.

Oriented plastic film, specifically biaxially oriented polypropylene film is widely used for packaging products, particularly foods. In its unmodified form, however, it does not have the gas and moisture barrier characteristics needed for packaging.

The present invention is directed to a film composition comprising a polymeric substrate having a surface which is modified by a maleic anhydride modified propylene homopolymer or copolymer, the modified surface of the polymer substrate has 15 a skin layer of ethylene vinyl alcohol copolymer (EVOH) upon which there is a transparent gas barrier layer.

In the film of this invention, there is excellent adhesion between the polymeric substrate and the transparent gas barrier layer. The film has excellent light and microwave transparency and will exhibit excellent ink adhesion without primer and excellent lamination bond strength without fracture of the barrier layer.

The invention relates to transparent multi-layer plastic films which have good gas and moisture barrier properties.

25 Typically, the transparent films permit the transmission of light waves through the film so that objects on either side of the film can be seen. The films also permit the transmission of microwaves and, therefore, they are useable in a microwave oven. Typically, the light transmission of the film is more than 50%, specifically, between 70 to 90%. Light transmission is measured using a XL-211 Hazegard Hazemeter, manufactured by Pacific Scientific Co., according to the ASTM test method D1003-61.

The multilayer film structure of this invention comprises 35 a substrate of polyolefin, typically polypropylene. The preferred polypropylene matrix material has the following characteristics: density of 0.91 g/cc; melting point of 160°C

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or higher; melt flow rate of 2 to 4.

The polyolefin substrate is modified by a maleic anhydride modified polypropylene. The maleic anhydride modified polypropylene skin layer can be prepared by any process, for example, the process disclosed in U.S. 3,433,777 and 4,198,327.

A simple process for its preparation is described in U.S. 5,153,074. The maleic anhydride modified polypropylene can be interblended into the substrate, by melt blending it with the substrate polyolefin, and/or it can be coextruded with the 10 substrate polymer. A commercially available maleic anhydride modified polypropylene or propylene copolymer has the following physical characteristics: density of 0.90 (ASTM D1505), Vicat softening point of 143°C (ASTM D1525); Shore hardness of 67°C (ASTM 2240); melting point of 160°C (ASTM D2117). The maleic 15 anhydride modified polypropylene acts as a tie layer which adheres the substrate to the EVOH. It is important to use the maleic anhydride modified polypropylene since without it the substrate is incompatible with the EVOH. Maleic anhydride modified polypropylene is sold commercially by a variety of 20 sources, e.g. it is sold under the tradename "ADMER" by Mitsui, "BYNEL" by DuPont, and "PLEXAR" by Quantum.

An EVOH layer is applied to the surface of the modified substrate. Generally the ethylene content of the EVOH will not impact the properties of the film, but the gas barrier properties of the film is a function of the proportion of ethylene in the EVOH. Typically, however, the ethylene content ranges from 30 to 50 mole % ethylene, but this can range from 20 to 80 mole %. The saponification number of the EVOH barrier can range from 50% or more. Conventionally, EVOH is made by saponifying ethylene vinyl acetate copolymer (EVA). If the saponification is incomplete, the end product will be a blend of EVOH and EVA. Since EVA is a tacky material (low melting point) which has poor gas barrier properties, its presence in the blend will hinder the gas barrier properties of the film.

In instances where the substrate is coextruded with the maleic anhydride modified polypropylene, it is important to apply the EVOH to the modified surface, otherwise, the EVOH will

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have difficulty adhering to the substrate. The EVOH can be applied in a thin layer by any effective process. The layer can range in thickness from 0.01 mil to 0.20 mil. Three processes of note are 1) coextrusion of a EVOH skin and the modified substrate with the use of a selector plug or multicavity die; 2) extrusion coating the EVOH layer onto the surface of the modified substrate; 3) co-lamination of a thin film of EVOH onto the surface of the modified polypropylene sheet.

For extrusion coating and co-lamination, it is useful, but not mandatory, to corona or flame treat the bonding surface of the substrate (the maleic anhydride modified polypropylene side) prior to application of the EVOH. This can minimize potential delamination problems.

A heat sealable film can be applied to the substrate on the side opposite to the EVOH. This can be accomplished by coextruding a heat sealable polymer, copolymer or trimer, such as ethylene-propylene-butene, onto the substrate. The heat sealable layer employed herein and applied during coextrusion can be an ethylene propylene (EP) copolymer or an ethylene propylene butene-1 (EPB) terpolymer which, as noted above is, typically, located opposite the EVOH skin layer. The ratio of ethylene to propylene to butene-1 can be from 0 to 15% ethylene, 70 to 100% propylene and 0 to 15% butene-1; that is, 2% ethylene, 94% propylene and 4% butene-1.

The multilayer films of this invention will generally range in thickness from 0.50 to 3.00 mil (12.5 to 75 μ m). The thickness of the core layer is usually about 90% of the total thickness of the film, but this can range from 79 to 94% with the other layers making up the difference. For instance, the 30 heat seal layer is typically 3 to 10% of the total thickness of the film and the maleic anhydride modified polypropylene is typically 2 to 6% of the total film thickness. The EVOH layer will range from 1 to 5% of the total film thickness.

The EVOH skin is then coated with a transparent barrier 35 layer by deposition of a transparent gas barrier material thereon. Typical materials useful as a barrier layer include metal compounds or alloys. Specific examples include silicon

carbide, oxides, ceramics such as silicon monoxide, silicon dioxide, aluminum oxide, magnesium oxide, boron oxide, calcium oxide and barium oxide. Organic compounds such as diamond-like compounds are also contemplated. Mixtures of two or more of the 5 foregoing barrier materials can also be employed, a specific mixture which has demonstrated advantages is a mixture of the following oxides: silicon dioxide, aluminum oxide, calcium oxide, magnesium oxide, boron oxide and barium oxide. a major proportion of the mixture is silicon dioxide which can 10 be more than 50% of the mixture. A number of other oxide materials can be used to make-up the remaining proportion. Usually, they are each present in amounts of less than 20% of the total amount of the mixture. A mixture of oxides have been found to provide improved barrier properties. Any typical 15 process for depositing the transparent barrier material onto the EVOH layer known in the art can be employed. The EVOH surface adheres well to the transparent barrier material.

The transparent barrier material can be deposited in numerous ways such as by physical methods, including thermal 20 heating, electron beam deposition, sputtering, electroplating or chemical methods such as end-products deposition inside a vacuum chamber by either chemical reactions or plasma polymerization.

We have found it advantageous to surface treat the EVOH 25 surface prior to depositing the transparent barrier material thereon. Suitable surface treatment is by flame or corona treatment.

If the film is to be used as a printable surface, it may be preferrable to adhere a printable surface to the film. Skin 30 polymers which can enhance printability include polyolefin homopolymers or copolymers.

As demonstrated in the following examples, which were actually conducted, the EVOH in combination with the transparent gas barrier layer improve oxygen barrier properties over other transparent structures. While, in these examples, polypropylene is the substrate, other polyolefin films may be used such as polyester, polyamide, polycarbonate and other polyolefins such

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as polyethylene or polybutene.

The following Examples illustrate the invention.

Example 1

This example, for comparative purposes, omits the EVOH 5 layer.

layer biaxially oriented film, A three having approximate final thickness of 0.70 mil (17.0 μ m), was prepared by coextruding a primary polypropylene layer (density 0.907, melting point 167°C, and a melt flow rate of 3) comprising 90% 10 of the film thickness and an oxide receiving upper surface layer of a maleic anhydride modified polypropylene (density 0.907, melting point 160°C), comprising 5% of the total film thickness, and a lower surface layer of heat sealable resin comprising 5% of of ethylene-propylene-butene-1 the total thickness 15 terpolymer. The coextrudate was quenched at between 30 to 50°C, reheated to 115-130°C and stretched in the machine direction 5 times using transport rolls operating at different speeds. After the desired machine direction orientation was obtained, the film was transversely oriented 8 times, at a temperature 20 profile ranging from 155 to 180 °C. Subsequently, the transparent gas barrier receiving upper surface layer was corona discharge treated. The film was vacuum deposited with silicon monoxide as a transparent gas barrier layer. Table 1, below, shows the film properties prior to vacuum deposition of the 25 silicon monoxide. Table 2, below, shows the film properties after vacuum deposition of the silicon monoxide.

Example 2

This is a comparison example of an opaque metallized film.

The opaque, metallized, four layer biaxially oriented film

30 structure was prepared following the process of Example 1 with
the exception that aluminum rather than silicon oxide was
deposited onto the maleic anhydride modified polypropylene.

Example 3

This example demonstrates a process for making a 35 transparent film in accordance with the present invention which has superior gas barrier properties.

A four layer biaxially oriented film structure was prepared

from the polypropylene core employed in Example 1. The same procedure as example 1 was followed except that a layer of EVOH was coextruded onto the modified polypropylene side of the substrate film. The ethylene content of the EVOH was about 48 mole %. The thickness of the EVOH layer was about 0.02 mil $(0.50~\mu\text{m})$. The resulting four layer coextrudate was quenched and biaxially oriented as in Example 1. Thereafter silicon monoxide was vacuum deposited onto the EVOH layer, in the same manner as disclosed in example 1.

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10 Example 4

This example demonstrates a process for making another transparent film in accordance with the present invention which has superior gas barrier properties.

A four layer biaxially oriented film structure identical 15 to the film structure of Example 3 was made with silicon dioxide as the transparent barrier layer.

Example 5

This example demonstrates a process for making another transparent film in accordance with the present invention which 20 has superior gas barrier properties.

A four layer biaxially oriented film structure identical to the film structure of Example 3 was made except the transparent barrier material was a mixture of various metal oxides containing more than 50 % silicon dioxide, and the 25 remaining proportion being aluminum oxide, magnesium oxide, boron oxide, calcium oxide and barium oxide.

In the following tables, gas barrier properties were measured on the films produced by determining the Oxygen Transmission Rate (OTR) (cc/100 in²/24 hr) which was measured at 73°F, 0% RH. The light transmission % was measured by a hazemeter (XL-211 Hazegard Hazemeter, manufactured by Pacific Scientific Co.) according to ASTM D1003-61. Several runs were conducted and the average of those runs is reported in the tables.

In the data of Table 2, the excellent water vapor barrier properties are demonstrated by the measured water vapor transmission rate (WVTR).

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TABLE 1
FILM PROPERTIES PRIOR TO DEPOSIT OF TRANSPARENT BARRIER
Example # Light Transmission (%) OTR
1 93 150

5

	TABLE 2					
	FILM PROPERT	IES AFTER	DEPOSITION	OF TRAN	SPAREN	T BARRIER
10	Example #	Barrier	Average	OTR	WVTR	Microwavable
		Material	Light			
			Trans-			
			mission			
			(%)			
15	1	Silicon	85	120	0.55	Yes
	(non-EVOH)	Monoxide				
	2	Aluminum	1	10	0.12	No
	(non-EVOH)					
	3	Silicon	84	0.15	0.40	Yes
20	(EVOH)	Monoxide				
	4	Silicon	82	2.7	0.47	Yes
	(EVOH)	Dioxide				
	5	Mixture	. 82	0.07	0.14	Yes ·
	(EVOH)	of				
25	•	oxides				

As shown in Table 1, before depositing the transparent gas barrier material, the light transmission properties of the film are rather good, but the oxygen barrier properties are poor. Thus, the film of example 1 would not be useful for most packaging purposes.

The data reported in Table 2 show that a high gas barrier transparent film was made in accordance with this invention. The EVOH-containing films having the transparent gas barrier deposited thereon have superior transparency and comparable gas barrier properties over non-EVOH-containing transparent and metallized films.

Comparing the data of Table 1 with the data of Table 2, it is apparent that the EVOH coupled with the metal oxide 40 contributes to the excellent gas barrier properties of the film, demonstrated by the OTR. That is, in the film of example 1 which was made without EVOH, prior to deposit of silicon monoxide, the oxygen transmission rate was 150. After depositing the silicon monoxide, the oxygen 45 transmission rate improved to a rate of 120. The films of examples 3, 4 and 5 which incorporate both the EVOH and the

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metal oxide barrier material achieved excellent oxygen transmission rates of 0.15, 2.7 and 0.07, respectively.

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CLAIMS

A transparent film composition which comprises a
polymeric substrate having at least one surface which is
modified by a maleic anhydride modified propylene homopolymer
or copolymer, the modified surface of the polymer substrate
has a gas barrier ethylene vinyl alcohol copolymer skin layer
and a transparent gas barrier located on the ethylene vinyl
alcohol copolymer skin layer.

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- 2. A film composition according to claim 1 in which the maleic anhydride modified propylene homopolymer or copolymer is a discrete layer.
- 3. The film composition of claim 1 in which the substrate comprises an oriented homopolymer or copolymer of propylene.
- 4. The film composition of claim 1 in which one side 20 of the film has a heat seal layer thereon.
- The film composition of claim 1 in which the transparent gas barrier layer is a metal oxide selected from the group consisting of silicon monoxide, silicon dioxide,
 aluminum oxide, magnesium oxide, boron oxide, calcium oxide and barium oxide and a mixture of two or more of the foregoing oxides.
- 6. A process for making a transparent film composition 30 comprising the steps of:
 - (a) providing a polymeric substrate film;
 - (b) modifying at least one surface of the polymeric substrate film with a maleic anhydride modified polypropylene homopolymer or copolymer;
- 35 (c) applying ethylene vinyl alcohol copolymer to the modified surface of the substrate; and
 - (d) depositing a transparent gas barrier material onto

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the ethylene vinyl alcohol copolymer surface formed in step (c).

- 7. The process of claim 8 in which the metal oxide gas 5 barrier material is selected from the group consisting of silicon monoxide, silicon dioxide, aluminum oxide, magnesium oxide, boron oxide, calcium oxide and barium oxide and a mixture of two or more of the foregoing oxides.
- 8. The process of claim 8 in which the film of step (c) is stretched in the machine direction about 4 to about 7 times and then stretched in the transverse direction about 5 to about 12 times and then flame or corona treated.

INTERNATIONAL SEARCH REPORT

International application No. PCT/US95/06618

A. CLASSIFICATION OF SUBJECT MATTER						
	:B23B 1/08, 27/00, 27/08, 15/04; CO8F 255/02					
US CL	:428/35.9, 36.6, 36.7, 446, 457, 461, 463, 515, 518, o International Patent Classification (IPC) or to both n	520, 522, 910 stional classification :	and IPC			
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C. DOC	UMENTS CONSIDERED TO BE RELEVANT					
Category*	Citation of document, with indication, where app	ropriate, of the relev	ant passages	Relevant to claim No.		
Υ	US, A, 5,153,074 (MIGLIORINI) 06	October 1992	2. Abstract:	1-8		
•	column 1, line 49 to column 3, line					
Α	US, A, 4,181,689 (NAGATOSHI E	T AL) 01 Jan	uary 1980,	1-8		
	see entire document.	,				
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Further documents are listed in the continuation of Box C. See patent family annex.						
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